Schemes for Simultaneous Large Transformer Ratio, High Efficiency, Low Energy Spread, High Charge of Accelerated Electron Beams by Tailored Wakefield Plateaus for Long Driver and Witness Bunches

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Plan

00 Problematic

- 01 Configurations for optimal parameters
- One driver and three witnesses bunch
- One driver and two witnesses bunch
- One driver and one witness bunch
- Two drivers and one witness bunch
- One driver and second bubble's witness witness
- 02 Instabilities' suppression approaches

03 Conclusions

Simulation info:

- 2.5D particle-in-cell numerical simulations via LCode;
- macro-particles;
- Gaussian electron distribution;

Units of measure

 $n_0 = 10^{18} \mathrm{cm}^{-3}$

 $r_b = 1.7 \mu \mathrm{m}$

 n_0 - for all densities,

 $\sqrt{4\pi n_0 mc^2}$ - for all fields, mc^2/e - for wakefield potential, $c\omega_p$ - for all distances and emittance, mc- for beam and plasma momenta, mc^2/ω_p - for beam angular momentum, n_0mc^2 - for energy densities, n_0mc^4/ω_p^2 - for integral energies, n_0mc^4/ω_p - for energy flux densities, n_0mc^5/ω_p^2 - for full energy flux

Problematic

- Plasma accelerators are a centimeter-scale source of GeV beams.
 - \rightarrow Leemans et al., Nature Physics 2, 696 (2006)

Conventional accelerators

- breakdown of the RF structure (100 MV/m)
- big sizes
- the energy loss by synchrotron radiation

Plasma wakefield accelerators

- gigavolt-per-metre (100 GV/m) electric fields
- compactness
- cheapness
- low repetition rate

Long Driver-bunch, Large Transformer Ratio, Plateau for Driver-bunch and Plateau for Witness-bunch but Small Charge of Accelerated Electrons and Small Accelerator Efficiency



driver's movement direction

Simultaneous requirements:

- ❑ the long profiled driver-bunches;
- a large total charge of accelerated electrons;
- □ large transformer ratio;
- □ high efficiency.

Three pairs driver-witness in three bubbles.

Identical plateaus on the decelerating and accelerating wakefields for the drivers and witnesses.

Large charge of accelerated electrons but small accelerator efficiency.



Three pairs driver-witness in three bubbles.

Identical plateaus on the decelerating and accelerating wakefields for the drivers and witnesses.

Large charge of accelerated electrons but small accelerator efficiency.



Large Charge of Accelerated Electrons, Large Transformer Ratio, and High **Efficiency** with Plateaus for the one Long Driver-bunch and for the three Witness-bunches



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Large Charge of Accelerated Electrons at Large Transformer Ratio and High Efficiency at Plateaus for One Driver-bunch and Two Witness-bunches



Spatial distribution of the density of two long profiled driver-bunches and of the profiled wintess-bunch

Spatial distribution of the plasma electron density, excited by two long profiled driver-bunches and reconstructed by the profiled wintess-bunch in blowout regime

Large Charge of Accelerated Electrons at Large Transformer Ratio and Low Efficiency at Plateaus for One Driver-bunch and Two Witness-bunches



Large Charge of Accelerated Electrons at Large Transformer Ratio and High Efficiency at Plateaus for One Driver-bunch and One Witness-bunch



Modified and Developed Schemes

Large Charge of Accelerated Electrons at Large Transformer Ratio and High Efficiency at Plateaus for Two Long Driver-bunches and for the Witness-bunch in the Accelerating Wakefield





The maximum current of the first bunch-driver is $Ib = 10.7 \ kA$ and for second $Ib = 19.7 \ kA$. The transformer ratio is 4.5

Instabilities in plasma wakefield accelerators

- Betatron oscillations
- Moving ions
- Hosing instability

- Low radius bunches
- Heavy atoms
- Nonlinear or close to zero focusing force

S.Diederichs, C.Benedetti, E.Esarey, M.Thevenet, J.Osterhoff, C. B. Schroeder. Phys. Plasmas. 29, 043101 (2022)

Hosing Instability in the Blow-Out Regime for Plasma-Wakefield Acceleration

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The electron hosing instability in the blow-out regime of plasma-wakefield acceleration is investigated using a linear perturbation theory about the electron blow-out trajectory in Lu *et al.* [in Phys. Rev. Lett. **96**, 165002 (2006)]. The growth of the instability is found to be affected by the beam parameters unlike in the standard theory Whittum *et al.* [Phys. Rev. Lett. **67**, 991 (1991)] which is strictly valid for preformed channels. Particle-in-cell simulations agree with this new theory, which predicts less hosing growth than found by the hosing theory of Whittum *et al.*



FIG. 3 (color). Hosing growth in four regimes. x_{b0} is the initial displacement of the beam centroid. We assume $\Delta_s = 0.1r_0$, $\Delta_L = 1c/\omega_p$ for the analytic curve in case (d). The slightly slower hosing growth in simulation (d) is caused by nonlinearity in beam-channel centroid coupling.

Weakly Nonlinear Mode with Narrow Bunches





Analytical investigations

T.J.Mehrling, R.A.Fonseca, A.Martinez de la Ossa, J.Vieira. Phys. Rev. Lett. 118(2017)174801;

A.Knetsch, B.Sheeran, L.Boulton et al. Phys. Rev. Accel. Beams. 24, 101302 (2021);

Regularization and **Advantages** of Wakefield in a Weakly Nonlinear Regime with Narrow Bunches



 $\begin{array}{ll} \mbox{1d} & \frac{dE_z}{dz} \approx 4\pi e n_b \ \rightarrow \ E_z \sim \xi - \xi_w(t), \\ \mbox{3d} & 4\pi r^2 E_r = \frac{4\pi}{3} e n_i r^3 \\ E_r = E_z = \frac{e n_i}{3} r \sim r \sim z - z_{bub}. \\ E_r = E_z = -\frac{e n_b}{3} r \sim - r \sim z_b - z. \end{array}$

from V. Maslov, R. Ovsiannikov, Numerical simulation of plateau formation by an electron bunch on the distribution of an accelerating wakefield in a plasma

References

W. P. Leemans, A. J. Gonsalves, H. - S. Mao Phys. Rev. Lett., v. 113, p. 245002, 2014.
A. J. Gonsalves, K. Nakamura, J. Daniels Phys. Rev. Lett., v. 122, p. 084801, 2019.
I. Blumenfeld, C.E. Clayton, F. - J. Decker Nature, Letters, v. 445, p. 741-744, 2007.
R. Assmann, E. Gschwendtner, K. Cassou CERN Yellow Reports: Monographs, v. 1, p. 91, 2022.
C. Benedetti, S. S. Bulanov, E. Esarey arXiv preprint arXiv:2203.08366. 2022.
S. Diederichs, C. Benedetti, M. Thévenet, E. Esarey, J. Osterhoff arXiv preprint arXiv:2206. 2022. 11967.
S. Diederichs, C. Benedetti, E. Esarey, M. Thévenet, J. Osterhoff Physics of Plasmas,. v. 29 (4), p. 043101, 2022.
V. Maslov, R. Ovsiannikov, N. Delerue et al Problems of Atomic Science and Technology, v. 6, p. 47, 2020.



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